

Integrated CMOS imaging array and dark current monitor

FIELD OF THE INVENTION

The field of the invention is the field of digital imaging using complementary metal oxide semiconductor (CMOS) technology.

BACKGROUND OF THE INVENTION

Modern imaging systems using charged coupled device (CCD) arrays and complementary metal oxide semiconductor CMOS arrays have come into increasing use for both industrial and consumer applications. CCD arrays have a longer history and much more time to solve problems arising in manufacture and use. CCD arrays have fewer dark current problems than CMOS arrays. However, CMOS arrays promise less expensive imaging, principally because other functions may be combined on the semiconductor substrate and the well honed techniques developed for computer technology may be used to produce the arrays.

Prior art CMOS arrays have an array of pixels arranged in rows and columns, where light is absorbed in the semiconductor substrate to generate electrons, and the electrons are stored until they are "read out" to generate an image. The charge stored for one pixel is generally sent through a column amplifier to generate a voltage, which is then converted to a digital signal in an analog to digital converter (ADC). The ADC has a minimum signal input V_{min} below which a zero is generated, and a maximum signal input V_{max} which saturates the ADC. Each column amplifier generally has an offset voltage which is added to the signal from the stored electrons, so that the signal sent to the ADC is V_{min} if no light is incident on the pixel and no electrons are stored. Since the amplification is slightly temperature and process dependent, the offset voltage must be adjustable, and means provided to send a "zero" or "dark" signal to the column amplifier so that the offset may be set to a voltage slightly less than V_{min} . The "dark" signal may be sent by dummy pixels which in effect ground the input to the amplifier.

1 However, electrons are generated in the pixel without light by spontaneous means which
2 are generally exponentially dependent on the temperature of the semiconductor material of the
3 pixel. The electrons so generated give rise to "dark current". Most light sensors produce "dark
4 current". The prior art of CMOS image arrays is deficient in that the "dark current" is not
5 accounted for in the case that the array temperature, and also the variation in temperature over the
6 array, changes with time. For the case of a CMOS integrated circuit application, where many
7 functions are carried out on a monolithic semiconductor chip, this is a serious deficiency. Each
8 part of the chip produces a different amount of heat at different times. Part of the array may be
9 near a section of the chip having a dense array of devices liberating a large amount of heat, so
10 that parts of the array will have a large temperature difference with respect to other parts of the
11 array. The temperature and variation in temperature may change as the device is used for
12 imaging, so that the dark current contribution to the image is variable and unaccounted for.

13 OBJECTS OF THE INVENTION

14 It is an object of the invention to provide an apparatus and a method to account for the
15 contribution of dark current to the output of a CMOS imaging array.

16 It is an object of the invention to provide an apparatus and a method to account for the
17 contribution of changing temperature to the contribution of dark current to the output of a
18 CMOS imaging array.

19 It is an object of the invention to provide an apparatus and a method to account for the
20 contribution of temperature variation over a chip to the contribution of dark current to the output
21 of a CMOS imaging array.

22 It is an object of the invention to provide a device to monitor dark current of a CMOS
23 imaging array.

24 It is an object of the invention to provide a device to monitor temperature over a CMOS
25 imaging array and calculate dark current contributions to the output of the CMOS imaging array.

26 SUMMARY OF THE INVENTION

1 The present invention is a system, apparatus and method for accounting for the dark
2 current provided in each pixel of a CCD or a CMOS imaging array during the exposure of the
3 array to light in an imaging process. The dark current from permanently darkened pixels, or the
4 temperature at one or more points on the semiconductor chip containing the array, is monitored
5 during the imaging process. The actual dark current measured from the darkened pixels, or a
6 dark current calculated from the temperature, is used in conjunction with a lookup table of dark
7 currents previously measured to calculate the contribution to the signal from each pixel expected
8 from the dark current generated in each pixel during the exposure. Both the temperature
9 dependent dark current and the fixed pattern dark current contribution is then subtracted from
10 the signal measured from each pixel, and the corrected image may then be displayed or used for
11 further manipulation or storage.

12 BRIEF DESCRIPTION OF THE DRAWINGS

13 Fig. 1 shows a block diagram of the method of the invention.

14 Fig. 2 shows a sketch of the apparatus of the invention.

15 Fig. 3 shows a sketch of the system of the invention.

17 DETAILED DESCRIPTION OF THE INVENTION

18 To achieve repeatability of performance of an imaging system, it is necessary to
19 compensate for or remove sensor and illumination artifacts in the system. In critical
20 applications, such as imaging of biological tissue for diagnosis of such diseases as cancer, the
21 performance of the imaging system is critical. The imaging system is made up of an
22 illumination system for illuminating an object, an optical system for projecting an image of the
23 object on to an image detector, and hardware and software for producing a computer and/or
24 human readable output for further evaluation. Our purpose in imaging an object is to quantify
25 the amount of light emitted at each point on the target, so as to most accurately map the radiant
26 emittance from each point on the object. For purposes of the following discussion, we make the

1 simplifying assumption, which need not be true, that transillumination and multiple-scattering
2 effects are sufficiently small that all of the light emitted can be considered to arise from
3 reflectance. As an example, a CMOS technology imaging array will be considered. Such a
4 CMOS array is generally constructed on a single chip of silicon, but may in fact be constructed
5 on a chip of any semiconductor material, including but not limited to silicon and silicon-
6 germanium, GaAs, and other near and far Infra-red imaging material. Other imaging array
7 techniques such as CCD arrays as known in the art or to be invented in future are also anticipated
8 by the inventors.

9 Known random noise sources include:

- 10 ● Photon Shot Noise
- 11 ● Pixel $kT C$ (capacitive) Noise
- 12 ● Dark Current Shot noise
- 13 ● Pixel source follower noise
- 14 ● Column amplifier source follower noise
- 15 ● Vertical sample and hold noise
- 16 ● Column amplifier transistor noise
- 17 ● $kT C$ noise on double sampling amplifier noise
- 18 ● Horizontal sample and hold
- 19 ● Output amplifier noise

20 Each of these types of noise is random, and cannot be removed by calibration.

21 However, effects that are fixed (i.e., “deterministic”) can be removed. These include:

- 22 ● dark current non-uniformity
- 23 ● amplifier offset variations
- 24 ● pixel quantum efficiency (QE) variation
- 25 ● amplifier gain variation

- illumination variation

The number of photons reaching the i^{th} pixel of the sensor from a particular spot on the target corresponding to the i^{th} pixel is proportional to the illumination (I_i) at that spot, multiplied by the (bidirectional) reflectance (R_i) of the same spot. (This “local” relation assumes that there are no significant transillumination or lens effects.) The photons reflected from the spot and received at the imaging array are converted to electrons at the i^{th} pixel of the sensor with quantum efficiency QE_i .

The number of electrons n_i at each pixel in the sensor is converted to a voltage V_i that is ultimately measured, i.e., the number of electrons at conversion time is what is output from the sensor.

However, electrons are created within the sensor pixel sites through two mechanisms.

- dark current
- photons converted to electrons

The number of electrons arising from dark current in the i^{th} pixel ($n_{d,i}$) is generally proportional to exposure time (τ) and exponentially dependent on temperature (T), which we express in functional form as follows:

$$(1) \quad n_{d,i} = f(T, \tau)$$

The number of photons $n_{p,i}$ converted to electrons is given by the number of photons reaching the sensor times the quantum efficiency of that pixel and is expressed by the proportionality expression:

$$(2) \quad n_{p,i} = k_i I_i R_i QE_i$$

1 Therefore the total number of electrons n_i in the pixel after the exposure is given by the number
2 from the Dark Current + the number generated by photons

3 (3)
$$n_i = n_{d,i} + n_{p,i} = f_i(T, \tau) + k_i I_i R_i QE_i$$

4 These electrons are passed to one or more amplifiers which have a cumulative gain (G_i) and an
5 offset (O_i) for each pixel. Thus, the signal (S_i) at the output of the amplifier (which is the output
6 of the sensor) can be expressed as follows:

7 (4)
$$S_i = G_i (f_i(T, \tau) + k_i I_i R_i QE_i) + O_i,$$

8 where i = pixel index. We can invert this equation and solve for the unknown reflectance R_i of
9 the target (e.g., skin). There are variations pixel to pixel in G_i , $f_i(T, \tau)$, k_i , I_i , QE_i and O_i .
10 We are now left with the task of determining these quantities pixel to pixel to solve for the
11 reflectance at that pixel.

12 In the most preferred embodiment of the invention some of the pixels of the array are
13 permanently covered or blacked over so that no light reaches them. The only signal that comes
14 from these darkened pixels is due to the dark current, multiplied by the pixel amplifier gains, and
15 a fixed dark pattern offset. As the temperature and exposure time of the sensor array changes,
16 the charge measured from these darkened pixels will predict the change in the dark current
17 contribution of the neighboring pixels which are exposed to light. In another preferred
18 embodiment, one or more darkened extra pixels, arrays of pixels, or discrete light detection
19 elements are placed in areas of the chip outside or inside the array. In another preferred
20 embodiment, the temperature of the array is monitored by one or more temperature monitors,
21 relative to a temperature when the dark current of the entire array has been measured, and the
22 relative dark current is calculated from the monitored temperature by external circuitry or by
23 circuitry integrated on the same monolithic substrate as the image array. In preferred
24 embodiments, the dark current or temperature variations across the array is calculated by

1 extrapolation and/or interpolation of the dark current or temperature monitor results at specific
2 points inside or outside the array.

3 At a constant current bias, the voltage drop across a silicon P-N diode junction shows
4 roughly a $-2 \text{ mV/}^\circ\text{C}$ temperature coefficient. Relative temperature measurements may be made
5 very inexpensively by measuring such a voltage drop. More accurate temperature measurements
6 may be made by a large variety of PTAT (proportional to absolute temperature) circuits which are
7 very well known in the art. Examples of such circuits are given in United States Patent
8 5,798,669, which is incorporated herein by reference.

9 Fig. 1 shows a block diagram of a preferred method of the invention. In block 10, a
10 CMOS imaging array is provided with a block to prevent any light from reaching at least one of
11 the pixels of the array. The blocked or darkened pixels are used to monitor the dark current in
12 the lighted pixels. In practice, many pixels must be blocked or darkened because the noise in
13 the measurement of just one pixel would be too great for accurate measurement of dark current.
14 The blocked or darkened pixels are preferably in one corner of the CMOS array. Another
15 preferable position for the blocked pixels is in each of the 4 corners of the (generally rectangular)
16 arrays. In another preferred embodiment, the pixels are on one or more edges, or in any
17 convenient place on the array, depending on the expected characteristics of the images.

18 In block 12, a very short exposure is taken. The exposure is so short that τ is small so
19 that the terms including $n_{d,i}$ and $n_{p,i}$ is negligible in equation 4, and $O_i = S_i$. We assume
20 that the offset changes little with temperature T and with exposure time τ , wavelength λ , and
21 exposure intensity. The short exposure may be made at any time during the calibration of the
22 imaging array to check that the offset has not drifted since the last time it was measured. The
23 signals S_i measured in block 12 are recorded as the offsets O_i for each pixel.

24 In block 14, the entire array is kept in the dark, and the signal output from the array is
25 measured for a long time exposure. In this case, the illumination I_i is zero, and the contribution
26 to the signal S_i due to the dark current $G_i (f_i(T, \tau))$ is determined from the results of step 14
27 and the offsets measured in step 12. Multiple exposures with different times τ are preferably
28 used to check that $G_i (f_i(T, \tau))$ is approximately linear in τ . The dark current measured from

the normally lighted pixels in block 14 is recorded, preferably in a look up table, as well as the dark current from the darkened pixels. In later exposures, the contribution of the dark current to the lighted pixels may be found from the values in the look up table using signal values measured from the darkened pixels when an image is taken. The dark current contribution to the illuminated pixels is proportional to the dark current contribution measured from the darkened pixels. If the temperature of the array changes, and the dark current in both the lighted and unlighted pixels changes exponentially with respect to the temperature.

In a normal setting, it is not convenient to block the light from the sensor (as with a shutter in a camera) so that the dark current lookup table is preferably constructed in the factory before the imaging system is shipped. However, measuring the dark current by blocking the light from impinging on the imaging array may be carried out in the field to check that the characteristics of the array have not changed. In an alternative preferred embodiment, the dark current contribution from the unilluminated array is measured and recorded and the same time as the relative or absolute temperature of the array is measured. When an image is recorded with the array illuminated, the temperature of the array is also monitored. The contribution of the dark current to the image signal is then calculated by assuming the dark current contribution varies exponentially with the temperature of the array. Such calculations are easily carried out by circuitry on the array chip, or by associated circuitry or computers off the chip.

In block 16, a uniformly reflecting target is illuminated with high enough illumination for a short enough time that the dark current signal is negligible with respect to the photon generated signal, and

$$(5) \quad S_i = G_i (k_i I_i R_\lambda QE_i) + O_i$$

Subtracting the measured values of O_i , which are relatively independent of the illumination level, exposure time, and wavelength λ of the illuminating light, and assuming that R_λ is constant over all the pixels for each wavelength λ , we can sweep all the variations in illumination, quantum efficiency, and gain into one measured effective gain coefficient

$$(6) \quad G_i^* = G_i (k_i I_i QE_i)$$

so that for an image of the target taken at the same illumination, wavelength, and exposure time as block 14.

$$(7) \quad S_i = G_i^* R_i + O_i + G_i f_i(T, \tau)$$

and the reflectivity R_i may be determined from the measured values of G_i^* , the offset O_i measured in block 12, and the dark current contribution $G_i f_i(T, \tau)$ determined from the measurements of block 14 and measurements of the signal from the darkened pixels. For differing illumination intensity, wavelength, and exposure time, the term multiplying R_i is calculated from the measured G_i^* to recover R_i .

Fig. 2 shows a sketch of a monolithic semiconductor chip 20 with a rectangular imaging array 22. Portions 24 of the imaging array are shown having the light blocked. The four corners of the array are shown blocked, but only one portion of the array may be blocked, and it may be in any position in the array 22. Separate arrays or detectors on the chip 20 may also be used. Portions 26 of the chip 20 preferably but not necessarily have devices such as amplifiers, analog to digital converters, memory and logic necessary to capture and image, translate the image from analog to digital form and to carry out manipulations on the digital image to remove the effects of dark current on the digital image. In the most preferred embodiment, such manipulations are carried out on the monolithic semiconductor chip. In other preferred embodiments, such manipulations may be carried out off chip or in a separate computer. Regions 24 also represent temperature monitoring devices for monitoring the temperature of the array 22. Such temperature monitoring devices may be located on the chip 20 inside and/or outside the array 22.

Fig. 3 shows a sketch of a system for using the apparatus and method of the invention. The object 30 is imaged on the imaging array 22 of chip 20 by an optical system exemplified by lens 32. Illumination is provided by illumination sources 34 which are preferably lamps and most preferably light emitting diodes (LED's) or laser diodes. Circuitry 38 controls the illumination sources 34 and the imaging array and electronic circuitry on chip 20. Circuitry 38 receives data from chip 20, and optionally displays results on a monitor 37 and optionally stores results on a storage device 39, which may be located near the optical system 32 or remotely located and reached by internet or other hard wire or software connection. Circuitry 38 may be located on chip 20, near chip 20 on a circuit board, or may be a separate computer.

Experimental Setup:

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1 We used a normal Melafind^(R) 100 camera from Electro-Optical Sciences, Irvington, NY,
2 which illuminates with a specific pattern of light for each wavelength, generally using different
3 patterns for LED's of different colors. Images were taken with the imaging sensor in the dark
4 for 1, 50, 100, 150, 200, 250 and 300 milliseconds. Then, images were taken of a photographic
5 paper target that had been exposed to a uniform flash density and developed, with the same
6 exposure times for each wavelength of illumination.

7 The images were calibrated using the method of Fig. 1, for a sensor array which had a
8 number of pixels in one corner blocked by aluminum foil.

9 Measurements were made after the chip had been run for a few minutes, and had a
10 temperature estimated to be 50°C. The signal to noise ratio measured from test exposures
11 increased from 15:1 with no correction for dark current to 200:1 with a correction for dark
12 current by the method of Fig. 1.

13 Obviously, many modifications and variations of the present invention are possible in
14 light of the above teachings. It is therefore to be understood that, within the scope of the
15 appended claims, the invention may be practiced otherwise than as specifically described.